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Interfacial Control of Magnetic Properties at LaMnO₃/LaNiO₃ Interfaces MARTA GIBERT, University of Geneva, MICHEL VIRET, CEA Saclay, ALMUDENA TORRES-PARDO, University of Paris-Sud, Complutense University of Madrid, CINTHIA PIAMONTEZE, SLS-PSI, PAVLO ZUBKO, University of Geneva, University College London, NICOLAS JAOUEN, Synchrotron SOLEIL, JEAN-MARC TONNERRE, CNRS Institut Neel, ALEXANDRA MOUGIN, University of Paris-Sud, JENNIFER FOWLIE, SARA CATALANO, University of Geneva, ALEXANDRE GLOTER, ODILE STPHAN, University of Paris-Sud, JEAN-MARC TRISCONE, University of Geneva — The functional properties of oxide heterostructures ultimately rely on how the electronic and structural mismatches occurring at interfaces are accommodated by the chosen materials combination. We discuss here LaMnO₃/LaNiO₃ heterostructures, which display an intrinsic interface structural asymmetry depending on the growth sequence with the LaMnO₃-on-LaNiO₃ interface being sharper than the LaNiO₃-on-LaMnO₃ one, which exhibits 2-3 unit cells intermixing [1]. Using a variety of synchrotron-based techniques, we show that the degree of intermixing at the monolayer scale allows interface-driven properties such as charge transfer and the induced magnetic moment in the nickelate layer to be controlled. Further, our results demonstrate that the magnetic state of strained LaMnO₃ thin films dramatically depends on interface reconstructions. [1] Gibert *et al.*, NanoLetters in press.

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